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wherein said first measuring device includes a first interferometer system, and said second measuring device includes a second interferometer system.

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137. (Amended) A method according to claim 68, further comprising:

measuring positional information of the first object;

and measuring positional information of the second object, wherein said positional information of the first object includes positional information of said first object in a direction which crosses said first direction, and said positional information of the second object includes positional information of said second object in a

direction which crosses said second direction.

138. (Amended) A method according to claim 68, 1 2 further comprising: measuring posit/ional information of the first object; 3

and 4 .

measuring positional information of the second object, wherein said positional information of the first object 6

includes information on rotation of the first object; and

said positional information of the second object

includes information on rotation of the second object. 9